Photolyses of Perfluoroacetic Anhydride and Perfluoropropionic Anhydride Vapours. New Sources of CF₃ and C₂F₅ Radicals

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Summary CF₃ and C₂F₅ radicals are conveniently produced by photolysis of perfluoroacetic and perfluoropropionic anhydrides respectively.

Few sources of CF₃ radicals exist that are free of complications and there are even fewer such sources of C₂F₅ radicals. We now report on new sources of these radicals.

The photolyses of the vapours of (CF₃CO)₂O and (C₂F₅-CO)₂O in the range 20—220 °C are quantitatively described by the overall equations (1) and (2). The addition of

$$(CF_3CO)_2O + \hbar v \rightarrow CO + CO_2 + C_2F_6$$
 (1)

$$(C_2F_5CO)_2O + h_V \rightarrow CO + CO_2 + C_4F_{10}$$
 (2)

radical scavengers such as NO, isobutene, or cyclohexene to either system did not affect the yields of CO or CO2 but reduced the respective yields of C_2F_6 and C_4F_{10} to zero. We conclude that the effective primary processes are described by equations (3) and (4), followed by (5) and (6).

$$(CF_2CO)_2O + h_V \rightarrow CO + CO_2 + 2CF_3$$
 (3)

$$(C_2F_5CO)_2O + h_V \rightarrow CO + CO_2 + 2C_2F_5$$
 (4)

$$CF_3 + CF_3 \rightarrow C_2F_6 \tag{5}$$

$$C_2F_5 + C_2F_5 \rightarrow C_4F_{10}$$
 (6)

Thus the anhydrides are convenient sources of CF3 and C₂F₅ radicals, the only limitation to their use being that wavelengths < 290 nm are needed for photolysis (λ_{max} ca. 240 nm). The yield of CO or CO2 is a direct measure of the number of radicals produced since equations (1)—(4) are obeyed quantitatively. Above 220 °C, thermal decomposition of (CF₃CO)₂O occurs¹ but CF₃ radicals are not produced. (C₂F₅CO)₂O is also stable up to 220 °C.

To test the behaviour of (CF₃CO)₂O as a source of CF₃ radicals, it was photolysed with methane and with cyclohexane where H-abstraction can occur as shown in equation (7). Values of $k_{\rm H}/k_{\rm 5}^{\frac{1}{2}}$ and the corresponding Arrhenius

$$CF_3 + RH \xrightarrow{k_H} CF_3H + R$$
 (7)

parameters are shown in the Table together with results obtained using other sources of CF3 radicals. The present results agree with previous work within experimental error.

TABLE

RH	$k_{\rm H}/k_{\rm 5}$ * at 400 K	$\log \left(A_{\rm H}/A_{5^{\frac{1}{2}*}}\right)$	$E_{\rm H}-\frac{1}{2}E_{\rm 5}\dagger$	Ref.
CH ₄	0.16	$5{\cdot}93\pm0{\cdot}32$	12.5 ± 0.7	a
	0.19	5.40 ± 0.14	11.2 + 0.2	2
cyclo-C6H12	132	5.18 ± 0.15	5.6 ± 0.2	a
-	100	$\textbf{5.44} \pm \textbf{0.20}$	6.3 ± 0.4	3

* Units, cm³/² mol⁻¹/² s⁻¹/². † Units, kcal mol⁻¹. a This work; ref. 2, radicals produced by photolysis of CF₃COCF₃; ref. 3, radicals produ ced by photolyses of CF₃COCF₃ and CF₃I

Perfluoropropionic anhydride was photolysed with cyclohexene where C2F5 radicals can either abstract H (rate constant $k_{\rm H}$) or add to the double bond. Assuming that the rate of addition is given by the "missing" C₂F₅ radicals, calculated from equation (8) we obtain equations (9) and (10).

$$R(Add) = R(CO) + R(CO_2) - R(C_2F_5H)$$
 (8)

$$E_{\rm H} - E_{\rm Add} = 2.53 \pm 0.12 \,\rm kcal \, mol^{-1}$$
 (9)

$$\log A_{\rm H}/A_{\rm Add} = 0.67 \pm 0.07 \tag{10}$$

When $(C_2F_5CO)_2O$ is photolysed with benzene vapour, the C₂F₅ radicals add to the ring with the addition becoming reversible above 110 °C. This behaviour parallels the reactions of CF₃ radicals with benzene.4

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